WHAT IS CLAIMED IS:

1. An electro-optical device, comprising:
data lines extending in a first direction above a substrate;
scanning lines extending in a second direction, the scanning lines crossing
the data lines;

pixel electrodes and thin film transistors disposed so as to correspond to regions in which the data lines and the scanning lines cross;

storage capacitors electrically connected to the thin film transistors and the pixel electrodes; and

a shield layer disposed between the data lines and the pixel electrodes, an upper electrode and a lower electrode between which a dielectric film forming each storage capacitor being supported include a first portion laminated along a plane parallel with one surface of the substrate and a second portion laminated along a plane that intersects the surface of the substrate at an angle, whereby the sectional shape of the capacitor includes a projecting shape.

- 2. The electro-optical device according to claim 1, the shield layer being electrically connected to the upper electrode of each storage capacitor.
- 3. The electro-optical device according to claim 1, the projecting shape being formed such that the lower electrode is formed so as to include a projecting portion from the substrate.
- 4. The electro-optical device according to claim 3, the lower electrode being formed of a light absorbing conductive material.
- 5. The electro-optical device according to claim 1, the projecting shape being formed by forming a projecting member below the lower electrode.
- 6. The electro-optical device according to claim 1, the projecting shape including a tapered shape.
- 7. The electro-optical device according to claim 1, the height of the projecting shape being 50 to 1000 nm.
- 8. An electro-optical device according to claim 1,
 the pixel electrodes being arranged in a matrix, and the scanning lines and
 the data lines being formed in light shielding regions corresponding to the matrix; and
 the storage capacitors being formed in the light shielding regions.
- 9. The electro-optical device according to claim 1, the projecting shape of each storage capacitor being formed along at least one of each scanning line and each data line.

- 10. The electro-optical device according to claim 1, the dielectric film constituting each storage capacitor including a plurality of layers including different materials, and constituting a laminated body including one of the layers which comprises a material having a dielectric constant higher than those of the other layers.
- 11. The electro-optical device according to claim 10, the dielectric film including a silicon oxide film and a silicon nitride film.
- 12. The electro-optical device according to claim 1, further comprising:

 as part of the laminated structure, an interlayer insulating film disposed as a base for each pixel electrode,

one surface of the interlayer insulating film being subjected to planarization processing.

13. An electro-optical device comprising:
data lines extending in a first direction above a substrate;
scanning lines extending in a second direction, the scanning lines crossing
the data lines;

pixel electrodes and thin film transistors disposed so as to correspond to regions in which the data lines and the scanning lines cross;

storage capacitors electrically connected to the thin film transistors and the pixel electrodes; and

a light shielding film disposed between each data line and each pixel electrode,

an upper electrode and a lower electrode between which a dielectric film forming each storage capacitor being supported include a first portion laminated along a plane parallel with one surface of the substrate and a second portion laminated along a plane that intersects the surface of the substrate at an angle, the sectional shape of the capacitor including a projecting shape.

14. An electronic apparatus including an electro-optical device comprising:

data lines extending in a first direction above a substrate;

scanning lines extending in a second direction, the scanning lines crossing
the data lines;

pixel electrodes and thin film transistors disposed so as to correspond to regions in which the data lines and the scanning lines cross;

storage capacitors electrically connected to the thin film transistors and the pixel electrodes; and

a shield layer disposed between the data lines and the pixel electrodes, an upper electrode and a lower electrode between which a dielectric film forming each storage capacitor being supported include a first portion laminated along a plane parallel with one surface of the substrate and a second portion laminated along a plane that intersects the surface of the substrate at an angle, the sectional shape of the capacitor including a projecting shape.

- 15. A device according to claim 1, the second portion being laminated along a plane substantially orthogonal to the surface of the substrate.
- 16. A device according to claim 13, the second portion being laminated along a plane substantially orthogonal to the surface of the substrate.
- 17. A device according to claim 14, the second portion being laminated along a plane substantially orthogonal to the surface of the substrate.
- 18. A device according to claim 1, the second portion being laminated along a plane orthogonal to the surface of the substrate.
- 19. A device according to claim 13, the second portion being laminated along a plane orthogonal to the surface of the substrate.
- 20. A device according to claim 14, the second portion being laminated along a plane orthogonal to the surface of the substrate.